

STD Oxide 5/9/2018	OLD RECIPE
Date	5/9/18
Standard Oxide Coat	
Coat time, min	10
Standard Oxide Deposition	
Deposition time, min	10
RF power setup, W	30
Pressure, mTorr	800
Gas flow, sccm	
SiH4	300
N2O	1420
T, C	~300
Thickness, nm	
Dep.rate, nm/min	
Index at 632.8nm	
Index at 1550nm	
Stress, MPa	
BHF, nm/min	
Std. clean, min	20

